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All Eligible Candidates as per list at Annexure

Subject: Selection for four posts of Scientific Attache i.e. one each in the Indian Missions at Washington, Moscow, Berlin and Tokyo by transfer on deputation (including short-term contract) basis.

Sir/Madam,

I am directed to refer to your application for the post of Scientific Attache in this Department and to say that the selection process for selection to the said posts will be held on **27th & 28th January, 2011 from 09.30 A.M. onwards in Technology Bhavan, New Delhi**. The selection process will involve the following stages:-

- (i) Group Discussion
- (ii) Presentation and Interview

2. The candidates who qualify in the Group Discussion Round will move to the Presentation / Interview Round. You are, therefore, requested to present yourself for the selection process at **08.30 A.M. sharp on 27th January 2011 in Room No. 30 Technology Bhavan, New Delhi**. In view of the weather condition in Delhi, it is advisable that you reach Delhi the previous day.

3. You are requested to bring with you original certificates regarding educational qualifications / experience for verification at the time of interview. It may be noted that in case you are fail to produce any of these documents, you may not be permitted to attend the selection process.

4. You will be reimbursed first class / third A/C rail fare whichever is less by the shortest rout from the place of correspondence address to New Delhi and back on production of railway ticket / ticket numbers. **In case you travel by air, reimbursement will be restricted to first class / third A/c class rail fare only if the journey is performed by National Carrier (Air India/Indian Airlines) on production of tickets / boarding pass.**(For outstation candidates)

5. You may make your own arrangement for stay in New Delhi at your own expense. No arrangement is being made in this regard by this Department.

Yours faithfully,

(Latha Gopakumar)
Under Secretary to the Govt.of India
Tel. 011-26590321 / 26590365